



IPW

PATENT
Customer No. 22,852
Attorney Docket No. 02887.0269-00

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
Katsuhiko HIEDA et al.)
)
Application No.: 10/804,159) Group Art Unit: 2818
)
Filed: March 19, 2004) Examiner: Mai Huong TRAN
)
For: SEMICONDUCTOR DEVICE AND) Confirmation No.: 7405
METHOD OF FABRICATING THE)
SAME)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

RESPONSE TO RESTRICTION REQUIREMENT

In a restriction requirement mailed on June 22, 2005, the Examiner required
restriction under 35 U.S.C. § 121 between

Group I: Claims 11, 15, 16, and 19, characterized by the Examiner
as drawn to a semiconductor device and classified in class 257, subclass
374; and

Group II: Claims 1-10, 12-14, 17-18, and 20, characterized by the
Examiner as drawn to a process of making a semiconductor device and
classified in class 438, subclass 207.

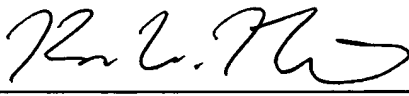
Applicants elect to prosecute Group II, claims 1-10, 12-14, 17, 18, and 20,
without traverse.

Please grant any extensions of time required to enter this response and charge any additional required fees to our Deposit Account No. 06-0916.

Respectfully submitted,

FINNEGAN, HENDERSON, FARABOW,
GARRETT & DUNNER, L.L.P.

Dated: July 20, 2005

By: 
Reece Nienstadt
Reg. No. 52,072

RVB/RWN